

## INFORMATION DISCLOSURE STATEMENT


Applicant : Sato et al.  
App. No : 10/540,056  
Filed : June 22, 2005  
For : POSITIVE RESIST COMPOSITION  
AND METHOD OF FORMING  
RESIST PATTERN  
Examiner : Chu, John S Y.  
Art Unit : 1795

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I hereby certify that this correspondence, and any other attachment noted on the automated Acknowledgement Receipt, is being transmitted from within the Pacific Time zone to the Commissioner for Patents via the EFS Web server on:

November 15, 2007

(Date)

  
Neil S. Bartfeld, Ph.D., Reg. No. 39,901

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 12 references to be considered by the Examiner. Also enclosed are 2 foreign patent references as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the mailing date of a final action and before the mailing of a Notice of Allowance. This Statement is accompanied by the fees set forth in 37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 11/15/07

By: 

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